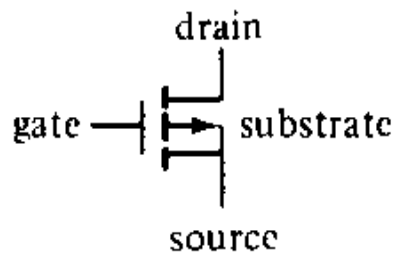
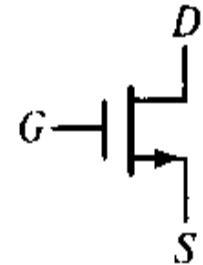
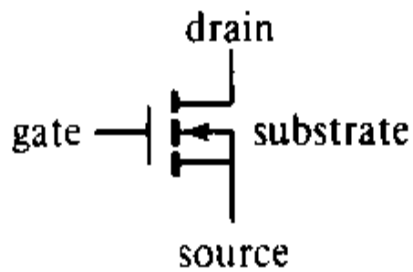
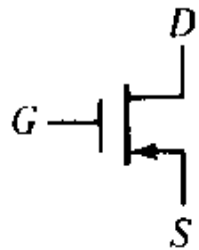


Metal oxide semiconductor



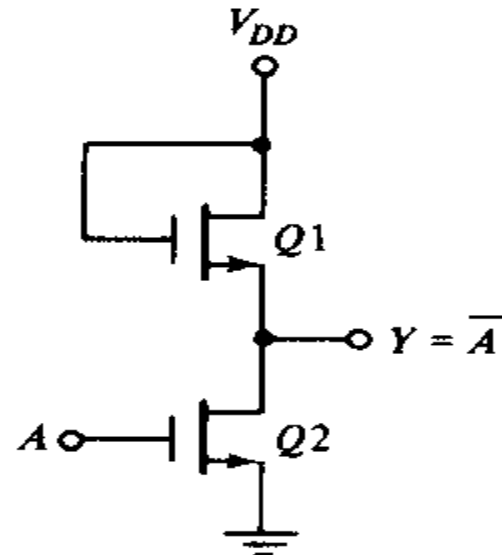
(a) p-channel



(b) n-channel

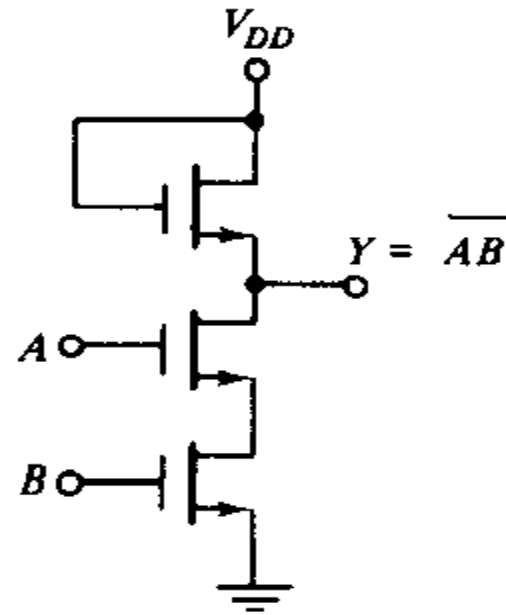
Inverter (NOT gate)

X	Y
0	1
1	0



NAND gate

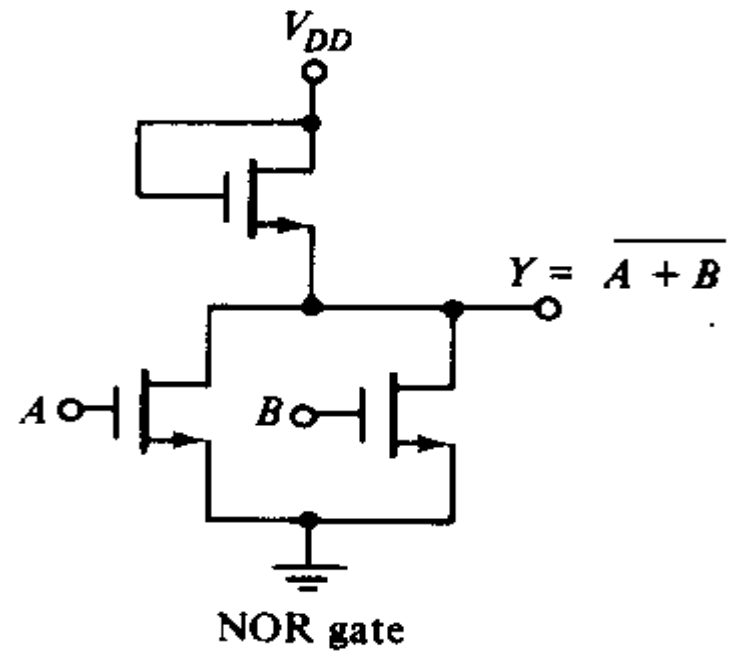
A	B	O/P
0	0	1
0	1	1
1	0	1
1	1	0



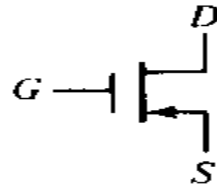
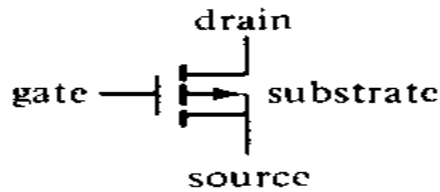
(b) NAND gate

NOR Gate

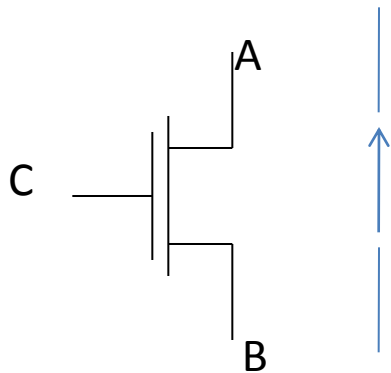
A	B	O/P
0	0	1
0	1	0
1	0	0
1	1	0



Implementing Gates Using MOSFET Integrated Circuits

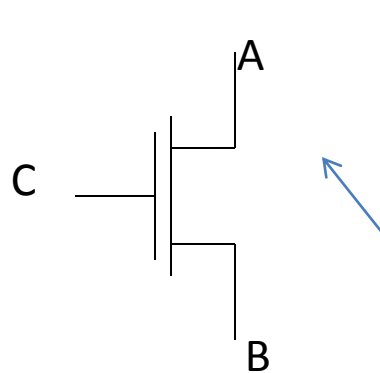


(a) p-channel



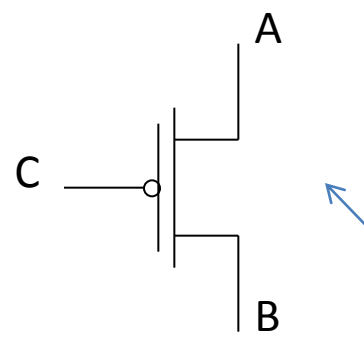
nMOS transistor

$C = 1$ when
A-B closed



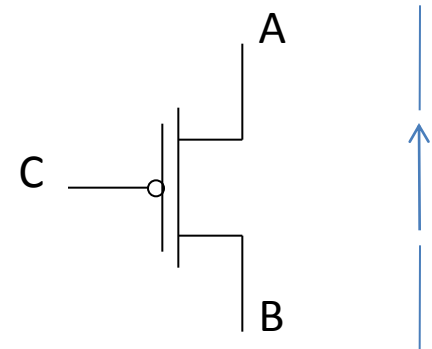
nMOS transistor

$C = 0$ when
A-B open



pMOS transistor

$C = 1$ when
A-B open



pMOS transistor

$C = 0$ when
A-B Closed